StudentBounty.com Q.2 What are soft and hard ferrites and where they are used? b. Why Iron Silicon alloys are preferred for power transformers, motors and generators? c. Give the applications of following material (i) Alnico (ii) Hard Ferrites Answer: PN. 2 (a) Soft magnetic material have a steepfy ising magnetisations curve. These material have high ( pumarbulities. The are used as cose material in magnetic ckts of electromagnetic equipment e.g. Soft 1200, silicon, steel elu Hand magnetic material are charederized by a high maximum megnetic energy product (B-H) max. These materials have gradually rising magnetisation cuevic. These materials are comployed as permanent magnets. Callon steel, tungsten steel, Cobalt steel etc. because Silicon Iron increases the electrical 6 resistivity of 1200, It increases permeability at low and moderate flux dentilies but decreasesait higher ym densities. Addition of silicon reduces hysteresis lass. The magnetostriction effect is also reduced Abrico find applications in loudspeaker, millionare (1) dences, motors, generators, méleis, magnetos sparators, communication devices and vending mechines Hard finite. The magnets are made in the form of mings, blocks and area. These are used in applications for land speckers, de motors, microwave over, magnetion tubes, travelling wave tubes, holding mapual etz.

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#### **DE54**

StudentBounty.com **ENGINEERING MATERIALS DE54** Q.3 a. Explain, what causes the decrease in resistivity of an intrinsic semiconductor at high temperature? b. What is Hall effect? What are the applications of Hall effect generator? c. What are important properties of semiconductor? d. Compare in brief the materials used in IC packaging. Answer: At room temps. covalent bonding is very strong (9) and no free electronis available ( there for semicorductor in pure state behave as an insulator but as temp. maesies their resisting dealess due to hagaline temp coefficient (b) when a current ceering conductor is placed. is in a magnetic field, al voltage is produced which acts is perpendicular direction to the cussent as well as to the magnetic hield. it thall affect course questor to measure (1) magnatic field shrights wood in flers meters (2) (I) The and runs is used in analogous computers (4) Indium anti monide is used to make compareses with high degree of sensitively (C) (1) The resistinty of semiconductor lies in between conductor and menleter. Le. 0.6 nm Resistance of conductors increases with the minease of Ca 1 temprature. but semi conductor resistance de creases with lenplatine. (17:) when a contribled quartity of a foreign material is - added to a semiconductor its properties are justices changed and it shows good adriductivity (d) DIP package is preferred because it is very to mount as mounting does not sepured banding of early Caramic DIP is prepared where power dissipation is more in comparación to plastic package metal com package in compassacion if preferred in power dusipation is much nigher flat pack is used in applications where methability and how weight are considerations

StudentBounty.com **ENGINEERING MATERIALS Q.4** What are different types of diode? Discuss each briefly. a. What are different methods of manufacturing transistor? Explain Alloy b. type method in detail. Answer: Different type of Diodes are (4) (1) Tunnel diede (1) Zener Dide (1) Schottley diede (N) Varacter diede (V) Photo diede (V) LEDS Power Diode (Vii) (i) Tunnel Drode: This duide is fabricated by doping the semiconductor materiels that will ferm the p-n. junction at a level one hundred to several thousand times that of a typical semiconductor divide . which roduce depletion layer and due to depletion, many Carriers can "tunnel" through (ii) Zenezi Diode: for these diode daping density is Very high. Zoner breekdown occurs at a nevere sias Vz. The Zerer voltage of a diode can be controlled by changing doping levels, producing an increase in humber of added impunities, will dedease 10

SE .	
DE54 ENGINEERING MATERIALS Schotthy Diodo: These doode have meted somkonductor junction. The semiconductor is usually in type solicions while a host of different metals such as molybdenium, platimums ate are used. Different construction tells migues results increased programy range, comer formand bias all me Varneter Diode: A simple duide under revere bias	
6	
Schottby Diodo: These doode have metal semiconductor	3
sunction. The semiconductor is usually in type silicon, while	2
a hast of different metals such as molybdenius, platinum	3.
et are used. Different construction techniques rasults increased propriency range, cover formand bias ale / m	13
conditions constitutes variater divide and acts as a voltage variable capacitor. The depletion region actions	
a dielectric between two conducting pretes . we with Ir	
of depletion layers varies with applied vollage	
LEDS: It is a Pri junctions when forward braised, emite light due to change conten recordination -1	
occurs at the junction, colorge mericans gives up -1	
energy in the form of light. and next. The indexal used for manufacture of LED's gallium assende,	
Used Tri ()	
Poroto Diode: It is a reverse biased functions chevice	
eight permitted to be pring the remaining sider	
Phosphide etc. Paroto Diode: It is a reverse biased junction diade usile light permitted to fall on one surface of the device across the function, kasping the remaining sides un illuminated. The pri junction is tembedded in fr	
cleare plastic package Power Diode: These diade are doughed to handle high	
A LAND REAL LAND A PLANADIADO M / AUTOR	
power and high entry power duide ale constructed applications. most of power duide ale constructed using silicon because of high current, temperature	
and piv many	
B. manuficting Transfor methods are Diffusiontype ??	
(1) Grown type (11)	
Alloylipe: This technique is also alled the fused concludation. The centre section is a thin wager ?	
of a type materies. The cante section of indium and for a for the materies of the ponder dots of the water and the.	
attached to apposite sides of the water and the	
of a type material this private and the wafer and the. attached to appointe sides of the wafer and the a whole structure is raised for a short time to a high temperature, alore the meeting point of Indium?	
ngn 1	
but helpen that a summer This	
but below that of germanium. The indus	
dissolves the germanium under it and former	
in contact with the base makeled recaystallizes	
with enough i drum concentration to change it from	
with enough idium concentration to charge it from In type to p type. The colloctor is made larger than	
the consister so that the collector subtands a large	
angle as viewed from the emitter Because of this	
geometrical arrangements, very little emitter curred	
bollows a deposion path which carries it to the	
base sather than to the collocter.	

**DE54** 

StudentBounty.com Q.5 a. Describe the construction detail of relays and List common type of relays. b. An air capacitor of capacitance  $0.005 \ \mu F$  is connected to direct voltage of 500V, is disconnected and then immersed to oil with a relative permittivity of 2.5. Find the energy stored in the capacitor before and after immersion.

Answer: 15 (a) Ralary consists of three basic clorents (1) an actualing element collad exciting Loie linkage to transfer the actustion/de-actuation Gil of infant to antpart (iii) Output elements or the contacts formaline Amstruce 1722 -terminals HINGE Busticons conlact insulation ter nine Baind Retren spring coil terminal Fig shows constantion of general purpose electromagnet raking - 9+ contains case sussanding by coil of wines The case to monted on metal prome. The movable part of rely is called armative when a voltage is applied to The coil, current flowing through it produce a magnetic bield in the case. In other words the case alters clastromagnetic and atleast the metal armature. - france

when the armature is attract to the case, the magnetic path is from the case through armative through the frame and back to the core on romeving the voltage, the spring attached to The corrective returns the armative to the original positions

. In this position there is small gap. Hence more power is needed to keep it's hold in the attracted positions

Common type q Relays (1) Latching Relay (i) Rotary stepping solar (1) Rotchet Rolay (iv) Polarized relay (v) so keroid 200 relay (i) Solid State Relay (viii) Power Rolay

Energy before immersion's (6)

EI= ± cN2 = ± × 0.005×106×(500) Jamal = 625×106J

When Immensied in oil, its capacitance is increased 2-5 times. Since charge is contant, voltage muist becomes 2.5 times. tence new capacilarie becomes 2.5 × 0.005 = 0.0125 4F and new nothings 500 = 200 V

E2 = 1 × 0.0125×106×(200)2 ( 3 mach. = 250 ×156 J

#### **DE54**

StudentBounty.com **Q.6** a. Explain the following processes of fabrication technology. (i) Oxidation (ii) Metallization **Answer:** (Pir 6 (a) oxidation: The An oxide layor is grown as the silicon surface. The chaeadantics (HF) to which undergoing siliton is impervious (b) the imposities used to dope the silicon do not penetrate the silicon duride. So when used with the masking techniques selective doping of specific region of this is accomplished Thormal oxidation is achieved in the presence of wrater vapours - The chemical reaction is Sit 2420 - \$ 5,02+242 The thickness of the oxide layar is generally of the order of 0.02-1. 2 him. the specific value solected depends on the bassin required to present dopant peretation Impiniby concentration, processing this processing time and processes temps are some of the factors that decide the thickness of the S.O2 layer. The SizNy (Silicon nitride) is used as a sandwich between two So, layor Metallization: This process is used to form the inter connections of the components on the Chip. These are bormed by the deposition of a thin layer of aluminium over the entire surface of the chip. Deposition is achieved by high vacuum evaporation viside a bell jor. The aluminium is heated untill it is repairies the gaseous malecules formed uniformly radiate in all directions & completely cover the water surface. A mask is used to define the connection pattan between the components and the unwanted alyminium is etched & removed in i there finiho

b. Describe 'Grown Junction' method of Fabrication in brief. Answer: Page Number 392 OF Text Book

#### **DE54**

- **DE54**
- **Q.7** a. Explain, how permittivity of a dielectric material is analogous to permeability of magnetic material?
  - b. State the factors which affects the dielectric loss of an insulating material.
  - c. Explain Dielectric breakdown in gasses.

Answer:

StudentBounty.com materies for developing across the when a weltage is applied across the amount of flux solenoid it will retries a certain amount of flux due to piece of magnetic material is introduced inside the solenoid, the amount of flux celus inside the solenoid, the amount of flux celus increases so inductance increases as the permeability increases so inductance increases by of the path for magnetic flux increases in case of capitale - the value of the capacitance increases as the bermitivity of the path for electric flux increases the permandely of magnetic material is different too different magnetic materials litewise permittivity is also different too different dielectrics (b) up the loss increases proportionately with the (iii) Presence of minduly increases. The loss (iii) Presence of minduly increases. The loss (iii) Temperature rise hosmally increase the loss (iv) Voltage increase caused mireases distriction All the gases are normally good indilators. and there belowiour is more on lease same when and their belowiour is more calleer same ustern twopilies to an electric field. I a Dc voltage is applied to a gas placed betweens two conducting impress. The electron present in the gos more to the anode and an equal number gree ione more toward cathod. As a result a current flow which follows of me law Schwith 69. At a certain voltage gas is selucted and current become almost constant (AB). If the voltage further increased at a certain value of the voltage the current the breakdown of the gas decine, the gas looses its, dielectric properties and turns into conductor. The voltage is voltage is called presched united of the gas S martin R 1.2 > V induial gave

0.8 a. What is Mobility? Describe in brief. Answer: Page Number 93 of Text Book

b. The resistance of a wire is 60  $\Omega$  or 25°C and 65  $\Omega$  at 75°C. Find the resistance of wire at 10°C and value of temperature coefficients at 0°C

#### **Answer:**

Q.9 Explain polarization mechanism and give the comparison of electronic, ionic and dipole polarization.

Answer: Page Number 142-143 of Text Book

#### **TEXT BOOK**

Introduction to Electrical Engineering Materials by C.S. Indulkar and S. Thiruvengadam, 4th Edition, Reprint 2006 Edition, S. Chand and Company, New Delhi.